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What is claimed is:

1.	A carrier head for chemical mechanical polishing, comprising
a base	having at least a portion formed of a polymer;

a mounting assembly connected to the base having a surface for contacting a substrate; and

a retainer secured to the portion of the base to prevent the substrate from moving along the surface.

- 2. The carrier head of claim 1, wherein the portion of the base is a ring-shaped body extended around a perimeter of the base.
- 3. The carrier head of claim 2, further comprising a dampening material secured between the retainer and the portion of the base.
- 4. The carrier head of claim 3, wherein the ring-shaped body includes at least one boss extending to contact the retaining ring.
- 5. The carrier head of claim 4, further comprising at least one screw extending through apertures in the base, the ring-shaped body and the damping material and into a receiving recess in the retaining ring to secure the retaining ring to the base..
 - 6. The carrier head of claim 5, wherein the boss surrounds the screw.
 - 7. The carrier head of claim 3, wherein the polymer includes polyphenylenesulfide, carbon fibers and polytetrafluoroethylene.
- 8. The carrier head of claim 7, wherein the polymer includes about 50-55% polyphenylenesulfide, 30-35% carbon fibers, and about 10-15% polytetrafluoroethylene.
 - 9. The carrier head of claim 7, wherein the damping material includes a polyvinylchoride thermopolastic.

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- 10. The carrier head of claim 1, wherein the polymer includes polyphenylenesulfide, carbon fibers and polytetrafluoroethylene.
- 5 11. The carrier head of claim 1, wherein the entire base is formed from the polymer.
 - 12. The carrier head of claim 1, further comprising a dampening material secured between the retainer and the portion of the base.

13. The carrier head of claim 1, wherein a bottom portion of the retainer includes at least one of carbon, fluoropolymer, and polyester.

- 14. A carrier head for chemical mechanical polishing, comprising: a base;
- a mounting assembly attached to the base having a surface for contacting a substrate;

a retainer secured to the portion of the base to prevent the substrate from moving along the surface, and

a dampening material secured between the retainer and the base.

- 15. The carrier head of claim 14, wherein the dampening material includes at least one of polyurethane and polyvinylchoride thermopolastic.
- 16. The carrier head of claim 14, wherein the base has at least a portion formed of a polymer and the retainer is secured to the portion of the base.
- 17. The carrier head of claim 16, wherein the portion of the base is a ring-shaped body extended around a perimeter of the base.
- 18. The carrier head of claim 17, further comprising at least one screw extending through apertures in the base, the ring-shaped body and the damping material and into a receiving recess in the retaining ring to secure the retaining ring to the base.

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- 19. The carrier head of claim 17, wherein the ring-shaped body includes at least one boss surrounding the screw and extending to contact the retaining ring.
- 20. The carrier head of claim 14, wherein a bottom portion of the retainer includes at least one of carbon, fluoropolymer, and polyester.
 - 21. A carrier head for chemical mechanical polishing, comprising: a base;

a mounting assembly attached to the base having a surface for contacting a substrate; and

a retainer secured to the portion of the base to prevent the substrate from moving along the surface, at least a bottom portion of the retainer including a material selected from the group consisting of polytetrafluoroethylene, perfluoroalkoxy, polyethylene terephthalate, polyetheretherketone, polyetherketoneketone, polybenzimidazole, an imidized thermoset polyimide, a semi-crystalline thermoplastic polyester, and a long molecular chain molecule produced from poly-paraphenylene terephthalamide.

- 22. The carrier head of claim 21, wherein the bottom portion of the retaining ring further includes carbon.
- 23. The carrier head of claim 22, wherein the bottom portion of the retaining ring further includes graphite.
- 24. The carrier head of claim 22, wherein the bottom portion of the retaining ring further includes carbon fibers.
- 25. An article for attachment to a carrier head, comprising:
 a ring-shaped body configured to be detachably secured at an outer perimeter of a carrier head, the ring-shaped body formed of a polymer and having a plurality of apertures therethrough and plurality of bosses surrounding the apertures.

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- 26. The article of claim 25, wherein the polymer includes polyphenylenesulfide, carbon fibers and polytetrafluoroethylene.
- 27. An article for attachment to a carrier head, comprising:
 a generally flat annular body configured to be detachably secured at an outer
 perimeter of a carrier head, the annular body formed of a dampening material and
 having a plurality of apertures therethrough.
- 28. The article of claim 27, wherein the dampening material includes at least one of polyurethane and polyvinylchoride thermopolastic.
 - 29. A retaining ring for a chemical mechanical polishing head, comprising: an upper portion configured to be secured to a base;

a bottom portion that includes a material selected from the group consisting of polytetrafluoroethylene, perfluoroalkoxy, polyethylene terephthalate, polyetheretherketone, polyetherketoneketone, polybenzimidazole, an imidized thermoset polyimide, a semi-crystalline thermoplastic polyester, and a long molecular chain molecule produced from poly-paraphenylene terephthalamide.

30. The retaining ring of claim 29, wherein the bottom portion of the retaining ring further includes at least one of graphite and carbon fibers.